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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/709,115	04/14/2004	Douglas D. Coolbaugh	BUR920030087US1	3114	
	7590 01/29/2007 OLSEN & WATTS		EXAM	EXAMINER	
22 CENTURY HILL DRIVE			HU, SHOUXIANG		
SUITE 302 LATHAM, NY 12110			ART UNIT	PAPER NUMBER	
			2811		
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SHORTENED STATUTOR	Y PERIOD OF RESPONSE	MAIL DATE	DELIVER	DELIVERY MODE	
3 MOI	NTHS	01/29/2007	PAP	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

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	Application No.	Applicant(s)			
Office Action Commence	10/709,115	COOLBAUGH ET A	۱L.		
Office Action Summary	Examiner	Art Unit	`		
	Shouxiang Hu	2811			
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence add	ress		
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).					
Status					
<ol> <li>Responsive to communication(s) filed on <u>07 Not</u></li> <li>This action is <b>FINAL</b>.</li> <li>Since this application is in condition for allowant closed in accordance with the practice under Extended</li> </ol>	action is non-final. nce except for formal matters, pro		merits is		
Disposition of Claims					
4) ☐ Claim(s) 1-21 is/are pending in the application. 4a) Of the above claim(s) 4-7, 9-20 is/are withdom 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1,3 and 8 is/are rejected. 7) ☐ Claim(s) 2 and 21 is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	rawn from consideration.	·			
Application Papers					
9) The specification is objected to by the Examiner 10) The drawing(s) filed on is/are: a) access applicant may not request that any objection to the consequence of the consequ	epted or b) objected to by the Edrawing(s) be held in abeyance. See ion is required if the drawing(s) is obj	37 CFR 1.85(a). ected to. See 37 CFF			
Priority under 35 U.S.C. § 119					
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of: <ol> <li>Certified copies of the priority documents have been received.</li> <li>Certified copies of the priority documents have been received in Application No</li> <li>Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> </ol> </li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>					
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO/SB/08)	4)  Interview Summary Paper No(s)/Mail Da 5)  Notice of Informal Pa	te			
Paper No(s)/Mail Date	6) Other:				

#### **DETAILED ACTION**

## **Pending Claims**

According to previous office actions, claims 1-21 are pending in this application; and claims 1-3, 8 and 21 remain active in this office action.

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 3 and 8, as being supported by applicant's elected species, are rejected under 35 U.S.C. 103(a) as being unpatentable over Li (Li et al., US 6,911,360) in view of Kobayashi (US 5,083,183).

Li discloses a resistor structure (Fig. 3), comprising: an electrically conductive region (64; silicide); first and second contact regions (28 and 38), wherein the first and second contact regions (28, 38) is electrically coupled with the conductive region; and, wherein in response to a current flowing in the electrically conductive region, a void region in therein expands due to electromigration so as to increase the resistance of the resistor structure (see col. 2, lines 1-20).

Li does not expressly disclose that the resistor can have an electrically conductive liner region in contact with the conductive region. However, as evidenced in

Kobayashi (Fig. 4), one of ordinary skill in the art would also readily recognize that such a liner (see layer 14) can be desirably formed so as to better protect the conductive region (13) in the resistor layer, wherein the liner (14) is in direct contact with the conductive region (13); the first and second contact regions (17/18) are electrically coupled with the conductive region (13) and the liner (14); and the first contact region (17/18) is in direct contact with the liner (14), wherein the liner (layer 14) can be regarded as an electrically conductive liner since it is formed of silicon which is not an insulator and can pass electrical current through it; and, it can become even more electrically conductive when it is naturally heated due to an electrical current passing through the resistor.

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to incorporate the conductive liner of Kobayashi into the resistor of Li, so that a resistor with better protection would be obtained.

Regarding claim 3, the void in Li expands naturally along the recited direction as it is inherent in electromigration.

# Allowable Subject Matter

Claims 2 and 21 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

# Response to Arguments

Applicant's arguments filed on November 07, 2006 have been fully considered but they are not persuasive.

Applicant's main arguments include: the cited prior art references do not teach the claimed invention, as the liner (layer 14) in Kobayashi cannot be electrically conductive. In response, it is noted that the liner (layer 14) of Kobayashi can be regarded as an electrically conductive liner since it is formed of silicon which is not an insulator and can pass electrical current through it. And, the silicon liner can become even more electrically conductive under various conditions, such as when it is heated due to an electrical current that passes through the resistor.

In response to applicant's argument that there is no suggestion to combine the references, the examiner recognizes that obviousness can only be established by combining or modifying the teachings of the prior art to produce the claimed invention where there is some teaching, suggestion, or motivation to do so found either in the references themselves or in the knowledge generally available to one of ordinary skill in the art. See *In re Fine*, 837 F.2d 1071, 5 USPQ2d 1596 (Fed. Cir. 1988)and *In re Jones*, 958 F.2d 347, 21 USPQ2d 1941 (Fed. Cir. 1992). In this case, Li teaches the claimed invention, except the liner. And, Kobayashi is cited to shown that it is art known that such a liner can be desirably formed so as to better protect the conductive region in the resistor layer. Accordingly, it would be well within the ordinary skill in the art to incorporate the liner of Kobayashi into the resistor of Li, so that a resistor with better protection would be obtained. And, such incorporated liner can be regarded as an

electrically conductive liner since it is formed of silicon which is not an insulator and can pass electrical current through it. It can become substantially electrically conductive, especially when a sufficient electrical current passes through the resistor.

#### Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shouxiang Hu whose telephone number is 571-272-1654. The examiner can normally be reached on Monday through Friday, 8:30 AM to 5:00 PM.

Application/Control Number: 10/709,115

Art Unit: 2811

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Richard T. Elms can be reached on 571-272-1869. The fax phone number

Page 6

for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information

SH January 16, 2007

> SHOUXIANG HU PRIMARY EXAMINER

system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.